Docket No. 740756-2709



In re Patent Application of:	)	
Koichiro TANAKA	)	Group Art Unit: 1725
Application No. 10/769,820	)	Examiner: Samuel Heinrich
Filed: February 3, 2004	)	Confirmation No. 9528
For: LASER IRRADIATION STAGE, LASER IRRADIATION OPTICAL SYSTEM, LASER IRRADIATION APPARATUS, LASER IRRADIATION METHOD, AND METHOD OF	)	

## REQUEST FOR RESTRICTION RESPONSE

Mail Stop **AMENDMENT** Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Request for Restriction Response mailed April 18, 2005, Applicant responds as follows: